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Xiabing LOU

Education & Research Experience

- 2011-2017 **PhD**, *Harvard University*, Chemistry. Atomic Layer Deposition of epitaxial high-k dielectric on Group III-V semiconductor devices.
- 2013-2015 **Second Field**, *Harvard University*, Energy Consortium. Studied economic benefits of energy storage devices, hybrid cars and environmental impacts of energy policies.
- 2007-2011 **Bachelor**, Fudan University, Chemistry, GPA: 3.63/4.00, Rank 3/88, Major GPA 3.91/4.00. Collaborating with SINOPEC Shanghai to develop novel gold catalyst for fine chemical production from crude oil.

Work Experience

- 2018-now **Sr. Device Engineer**, *Cambridge Electronics, Inc.*, Leading ALD dielectric development on GaN based power swtich devices.
- 2017-2018 **Business Analysis Manager**, *T-Mobile US, Inc.*, In charge of analyzing Telecom industry technology trend and support the leadership for 5G strategy roll-out

Journals Reviewed

Catalysis Science & Technology
Thin Solid Films
Physics Letters A
Microscopy and Microanalysis
Journal of Nanomaterials

Selected Publications and Conferences

Xia-Bing Lou, Hong Zhou, Sang Bok Kim, Sami Alghamdi, Xian Gong, Jun Feng, Xinwei Wang, Peide D. Ye, Roy G. Gordon*, Epitaxial Growth of MgxCa1-xO on GaN by Atomic Layer Deposition, *Nano Letters*, 2016, **16**, 7650–7654

Xia-Bing Lou, Lin He, Yue Qian, Yong-Mei Liu, Yong Cao*, Kang-Nian Fan, Highly Chemoand Regioselective Transfer Reduction of Aromatic Nitro Compounds using Ammonium Formate Catalyzed by Supported Gold Nanoparticles, *Advanced Synthesis and Catalysis*, 2011, **353**, 281–286

- H. Zhou, **X. Lou**, et. al., DC and RF Performance of AlGaN/GaN/SiC MOSHEMTs With Deep Sub-Micron T-Gates and Atomic Layer Epitaxy MgCaO as Gate Dielectric. *IEEE Electron Device Letters*, 2017, **38**, 1409-1412
- H. Zhou, **X. Lou**, et. al., Enhancement-mode AlGaN/GaN Fin-MOSHEMTs on Si substrate with atomic layer epitaxy MgCaO. *IEEE Electron Device Letters*, 2017, **38**, 1294-1297

J. Feng, **X. Lou**, et. al., Direct-Liquid-Evaporation Chemical Vapor Deposition of Nanocrystalline Cobalt Metal for Nanoscale Copper Interconnect Encapsulation. *ACS Applied Materials & Interfaces*, 2017, **9**, 10914-10920

S. Ren, M. A. Bhuiyan, J. Zhang, X. Lou, et. al., Total Ionizing Dose (TID) Effects in GaAs MOSFETs With La-Based Epitaxial Gate Dielectrics. *IEEE Transactions on Nuclear Science*, 2017, **64**, 164-169

Xiabing Lou and Roy G. Gordon*, Epitaxial Growth of MgCaO on GaN by Atomic Layer Deposition *42nd International Symposium on Compound Semiconductors*, **2015**, Santa Barbara, CA

H. Zhou, **X. Lou**, et. al., High Performance InAIN/GaN MOSHEMTs Enabled by Atomic Layer Epitaxy MgCaO as Gate Dielectric. *IEEE Electron Device Letters*, 2016, **37**, 556-559

Zhou, Hong; **Lou, Xiabing**; et. al., InAIN/GaN MOSHEMTs with High Drain Current of 2.3 A/mm High On/Off Ratio of 1012 and Low SS of 64 mV/dec Enabled by Atomic-Layer-Epitaxial MgCaO as Gate Dielectric, **Device Research Conference** (2015)1-2

Zhou, Hong, **Lou, Xiabing**, et. al., AlGaN/GaN MOSHEMT on Si Substrate with High on/off Ratio and High Off-state Breakdown Voltage Enabled by Atomic Layer Epitaxial MgCaO as Gate Dielectric, *46th IEEE International Electron Devices Meeting* (2015)1-3

Zhang, Jingyun; **Lou, Xiabing**; Si, Mengwei; Wu, Heng; Shao, Jiayi; Manfra, Michael J.; Gordon, Roy G.; Ye, Peide D.*, Inversion-mode GaAs wave-shaped field-effect transistor on GaAs (100) substrate, *Applied Physics Letters*, 2015, **106**, 073506.1-073506.4

Lin He, **Xia-Bing Lou**, Ji Ni, Yong-Mei Liu, Yong Cao*, He-Yong He, Kang-Nian Fan, Efficient and Clean Gold-Catalyzed One-Pot Selective N-Alkylation of Amines with Alcohols, *Chemistry - A European Journal*, 2010, **16**, 13965–13969

Lin He, Feng-Jiao Yu, **Xia-Bing Lou**, Yong Cao*, He-Yong He and Kang-Nian Fan, A novel gold-catalyzed chemoselective reduction of ,-unsaturated aldehydes using CO and H_2O as the hydrogen source, *Chem. Commun.*, 2010, **46**, 1553-1555

Xinwei Wang, Omair I. Saadat, Bin Xi, **Xiabing Lou**, Richard J. Molnar, Tomás Palacios and Roy G. Gordon, Atomic layer deposition of Sc_2O_3 for passivating AlGaN/GaN high electron mobility transistor devices, **Applied Physics Letters**, 2012, **101**, 232109

Patent #: CN102086155A. A novel catalysis method for reduction synthesizing amine, alcohol, olefin and alkane with supported gold nano particles2011.06.08

Awards and Honors

2014 & 2012 Excellent Teaching Award of Harvard University

2013-2015 Harvard University Center for The Environment Fellowship

2008-2010 National Scholarships of China (4 out of 122)

2009-2010 Excellent Student of Fudan University (5 out of 122)

2008-2009 National Scientific Base Scholarships

Projects

MgCaO Established an ALD epitaxial growth method of MgCaO film on GaN substrate. MgCaO is epitaxy serving as a high-k dielectric material for GaN based HEMT devices which is potentially applicable in next generation power inverter and electrical vehicles.

 La_2O_3 Designed epitaxial La2O3 ALD growth method for both GaAs(111) and GaAs(100) surfaces. Epitaxy In GaAs(100) surface, (111) surface was exposed by etching the surface into a "W" shape fin structure. Therefore, the challenge of growing La2O3 epitaxy on GaAs(100) is solved.

Building Design and construction of two different ALD reactors. Each reactor has 8 different Reactor precursor sources and the combination provide the capability for a variety of material including WN, La_2O_3 , MgCaO, Al_2O_3 , etc. The systems are controlled by embedded systems (arduino and raspberry Pi) and the software was written with Python by myself.

TEM analysis Wrote a software to analyze TEM diffraction pattern. The software is written with Matlab software and Python, and provides the capability of converting the image pattern into lattice constant data

Energy Built a model to analyze the economic potential of energy storage devices(like Tesla Power Storage Wall and flow battery) in both US(low renewable energy) and Germany (high renewable Economics energy) market. By assuming a deregulated electricity market, the potential of energy storage device in Germany can break even in 7 years by arbitraging the fluctuation of electricity prices, while in US it takes 20 years.

Skills

Technology Transmission Electron Microscopy, X-ray Diffraction Crystallography, Atom Probe Tomography, Designing and constructing Atomic Layer Deposition systems, X-ray photoelectron spectroscopy, Fast Fourier Transform Infrared, Photo and E-beam lithography, Metrology, Focused Ion Beam

Computer Expert in Linux system. Proficient with MS office software and Matlab. Experienced in systems and Latex, html, C++ and Python. Programing